

What is claimed is:

1. A method of preserving a cosmetic comprising mixing therein a substantially paraben-free endermic liniment composition comprising an antiseptic/antifungal agent for inhibition of microbial growth in cosmetics, said agent comprising:

0.1-3 wt% 2-n-butyl-2-ethyl-1,3-propanediol,  
2.0-5.0 wt% 1,3-butylene glycol, and  
water.

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2. The method of claim 1, wherein said composition is a moisturizing cream comprising 40-60 wt% water.

3. A method of preserving a cosmetic comprising 15 mixing therein an antiseptic/antifungal agent, said agent comprising:

(a) 0.1-3.0 wt% 2,2-dialkyl-1,3-propanediol; and  
(b) 0.1-15.0 wt% of a diol selected from the group consisting of propylene glycol, 1,3-butylene glycol, 20 1,2-pentanediol, dipropylene glycol, 1,2-butylene glycol, 2,5-pentanediol, 2,4-pentanediol, 2-methyl-2,5-pentanediol, 1,2-hexylene glycol, and 1,6-hexylene glycol.

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